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Journal of Power Sources 171 (2007) 990-998

www.elsevier.com/locate/jpowsour

Nanocrystalline TiO₂ film with textural channels: Exhibiting enhanced performance in quasi-solid/solid-state dye-sensitized solar cells

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> Received 9 March 2007; received in revised form 3 July 2007; accepted 5 July 2007 Available online 10 July 2007

Abstract

Novel nanocrystalline TiO₂ films with the textural channels are obtained for dye-sensitized solar cells (DSSCs). The textural channels consisting of the cracks on the surface and the nanopores with average diameter of about 41 nm are produced by packaging ZnO nanowires with diameter of 30-50 nm into TiO₂ films and subsequently etching ZnO nanowires by hydrochloric acid. The performances of DSSCs based on novel TiO₂ films (with the textural channels) and traditional TiO₂ films (without the textural channels) are investigated, respectively. When two kinds of typical quasi-solid-state electrolytes and one kind of solid-state electrolyte are used, the energy conversion efficiencies of DSSCs from novel TiO₂ films are improved by 20-30% compared to that from traditional TiO₂ films. The reasons for the great improvement are investigated chiefly by UV–vis absorption spectra, field emission-scanning electron microscope (FE-SEM) and electrochemical impedance spectroscopy (EIS) technique. The results show that the introduction of the textural channels facilitates better penetration of quasi-solid/solid-state electrolytes into the nanopores of novel TiO₂ films and thus results in better interfacial/electrical contact and faster interfacial reaction. © 2007 Elsevier B.V. All rights reserved.

Keywords: TiO₂ film; Textural channel; Dye-sensitized solar cells; Quasi-solid/solid-state electrolytes

1. Introduction

Dye-sensitized solar cells (DSSCs) have received considerable attention as a cost-effective alternative to conventional solar cells [1–7]. Above 10% light-to-electricity conversion efficiency has been achieved in DSSCs with organic solvent-based electrolyte [8]. However, the presence of organic liquid electrolytes in cells results in some problems such as leakage, evaporation of solvent, high-temperature instability and flammability. Therefore, many attempts have been made to substitute liquid electrolytes with quasi-solid/solid-state electrolytes, for example, p-type semiconductors [9], organic hole-transport materials [10,11], low molecular weight gels [12], ionic liquid-based gel electrolytes [13–16], polymer gel electrolytes [17–22], plastic crystal electrolyte [23–25] and solid polymer electrolytes [26–30]. It is well known that the interfacial contact and reaction between the dye-sensitized TiO₂ film and the electrolyte are important factors in determining the electron transfer efficiency and consequently the overall solar-to-electric conversion efficiency. Unfortunately, quasi-solid/solid-state electrolytes are difficult to penetrate into the nanopores of TiO₂ film compared with organic liquid electrolytes, which usually leads to poorer interfacial contact/reaction and lower conversion efficiencies of quasi-solid/solid DSSCs compared with those of the liquid versions. It has been reported that better wetting and pore filling of TiO₂ film by organic hole-transport materials (even having relative lower carrier mobility) can improve interfacial contact and reaction and thus cause better conversion efficiencies [31]. Therefore, to promote the interfacial contact and reaction, the wetting and pore filling of the nanoporous TiO₂ layer by the quasi-solid/solid-state electrolyte should be maximized. Some works have been done to modify quasi-solid/solid-state electrolytes, such as adding amorphous oligomer [27] or nanoparticles [7,26,30] into the electrolyte. To the best of our knowledge, little work,

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^{0378-7753/\$ –} see front matter © 2007 Elsevier B.V. All rights reserved. doi:10.1016/j.jpowsour.2007.07.007

however, was reported to modify TiO_2 film for the same aim.

Generally, the reactions are more effective when the transport paths, through which molecules move into or out of the nanostructured materials, are included as an integral part of the architectural design [32,33]. Moreover, the liquid and quasisolid/solid-state materials may more easily diffuse into the nanopores of the nanostructured materials through the suitable transport paths. These transport paths may be realized through a hierarchical combination of independently controlled, wellconnected meso- and macro-pores [33]. It is well known that many mesoporous materials, such as hexagonal mesoporous silica [34] and TiO₂ [35-38], consist of smaller domain size with short channels and larger textural mesoporosity. Grätzel et al. [35] and our group [36] have investigated mesoporous TiO₂ films exhibiting greatly enhanced performance in DSSCs (with organic liquid electrolytes). Such mesoporous TiO₂ films are applicable for quasi-solid/solid-state DSSCs, but the performance of actual cells is limited by incomplete filling of mesopores due to the small pore size (<10 nm) [38]. Karthikeyan et al. [39] investigated the influence of three different nanocrystalline TiO₂ films, prepared from three different routes, namely sol-gel, thermal and colloidal-microwave process, on the performance of solid-state DSSCs. And they found that the optimal pore and morphological structures of TiO₂ film were important for efficient functioning of solid-state DSSCs, but the conversion efficiencies were low (<1%). Therefore, the design of TiO_2 film with more suitable meso- and macro-pores may be more beneficial to the improvement of the interfacial contact and reaction between the dye-coated TiO₂ film and the electrolyte. Herein, we reported a simple approach to prepare novel nanocrystalline TiO₂ films with the textural channels (micro-sized cracks on the surface and about 41 nm nanopores in the film bulk) via packaging ZnO nanowires into TiO₂ films and subsequently etching ZnO nanowires by hydrochloric acid. These textural channels in TiO₂ film enhanced the penetration of quasi-solid/solid-state electrolytes and therefore led to the obvious improvement of the performance of DSSCs.

2. Experimental

2.1. Materials

All the regents used were of analytical purity. Zn $(CH_3COO)_2 \cdot 2H_2O$, NaOH, KOH, ethanol, poly(ethylene glycol) (PEG, MW = 20,000), PEG (MW = 400), 2-propanol, acetone, TiCl₄, titanium butoxide, petroleum ether (60–90 °C) and hydrochloric acid were purchased from Sinopharm Chemical Reagent Corporation (China). Titanium tetraisopropoxide, I₂, LiI, *N*-methyl-benzimidazole (NMBI), polyethylene oxide (PEO, $M_w = 2 \times 10^6$), poly(vinylidene fluoride)(PVDF, $M_w = 1 \times 10^5$), 1,2-dimethoxyethane (DME) and poly(vinylidenefluoride-*co*-hexafluoropropylene) (PVDF-HFP) were obtained from Aldrich. TiO₂ nanoparticle (P25) and fumed silica nanoparticles (A380, 12-nm primary particles size) were purchased from Degussa. Propylene carbonate (PC) and 4-*tert*-butylpyridine were obtained from Acros. *cis*-bis(isothiocyanato) -bis(2,2'-bipyridyl-4,4'-dicarboxylato) ruthenium(II) (abbreviated as N3) was purchased from Solaronix (Switzerland). 1-Methyl-3-propylimidazolium iodide (MPII) was synthesized according to literature [40]. Transparent conductive oxide glass (TCO, F-doped SnO₂-coated glass, 85% transmittance in the visible, 15 Ω square⁻¹) was received as a gift from the General Electronics Company.

2.2. Preparation of nanocrystalline TiO_2 films without/with the textural channels

TCO glass substrates were immersed in a saturated solution of KOH in 2-propanol overnight, rinsed with acetone, ethanol and doubly deionized water successively, and dried in a nitrogen stream. To improve the ohmic contact and to avoid short circuiting and loss of current through recombination at TCO electrode, a compact (about 100 nm-thick) TiO₂ layer was first deposited onto TCO glass as follow [42]. TCO glass was dipped into the mixture of titanium butoxide and petroleum ether (2:98, v/v), taken out carefully, hydrolyzed in air for 30 min, and sintered in oven for 20 min at 450 °C.

ZnO nanowires with diameter of 30-50 nm and length of $0.5-2 \,\mu\text{m}$ were prepared according to the literature [41]. About 120 g/L TiO₂ colloidal dispersion, containing 40 wt.% poly(ethylene glycol) (MW = 20,000), was prepared by the hydrolysis of titanium tetraisopropoxide according to our previous report [3]. One hundred and sixty-five milligrams asprepared ZnO nanowire was dispersed in 1 mL ethanol. Then this nanowire suspension was mixed with 10 mL TiO2 colloidal dispersion and consequently stirred for over 2 days. Then several drops of TiO₂ colloidal dispersion containing ZnO nanowire was spread uniformly (using the doctor-blading technique) onto the top of the compact TiO₂ layer followed by annealing at 450 °C in air flow for 30 min. About 10- μ m-thick novel TiO₂ films containing ZnO nanowire (denoted as ZnO-TiO₂ film) were obtained by repeating the above procedure several times. Acid treatment (etching ZnO nanowire) was carried out by soaking ZnO-TiO₂ film in 0.5 M hydrochloric acid at 75 °C for over 1 day. ZnO-TiO₂ films before and after the acid treatment were denoted as ZnO-TiO₂-BT and ZnO-TiO₂-AT, respectively. For comparison, 10-µm-thick traditional nanocrystalline TiO₂ films were prepared by using TiO₂ colloidal dispersion without any nanowire [3]. The traditional nanocrystalline TiO₂ films before and after the same acid treatment were denoted as TiO2-BT and TiO₂-AT, respectively. After the acid treatment, all TiO₂ films were still strongly adherent to TCO glass substrates.

2.3. Construction of DSSCs based on nanocrystalline TiO_2 films without/with the textural channels

TiO₂-AT and ZnO-TiO₂-AT were soaked in the 0.2 M aqueous TiCl₄ solution overnight [2]. After being washed with deionized water, they were heated again at 450 °C for 30 min. Dye sensitization of these films was carried out by immersing the films (still warm, i.e., 80-100 °C) in ethanol solution containing 0.5 mM N3 dye for over 12 h. The N3-coated TiO₂ films

were dipped in 4-*tert*-butylpyridine for 15 min and then used as working electrode. The counter electrode was TCO glass on which 200 nm thick layer of Pt was deposited by sputtering. The electrodes were separated by a 40- μ m-thick hot-melt ring (Surlyn 1702, DuPont).

In order to compare the performance of cell fabricated from two kinds of TiO₂ films, we selected an organic liquid electrolyte (Liquid-S0), two kinds of quasi-solid-state electrolytes (Quasisolid-S1, Quasi-solid-S2) and a solid-state electrolyte (Solid-S3) as model electrolytes. Liquid-S0, composed of 0.03 M I₂ and 0.3 M LiI in propylene carbonate, was attracted into the interelectrode space by capillary forces. Quasi-solid-S1 was the ionic liquid-based gel prepared by mixing fumed silica nanoparticles (5 wt.%) and the MPII solution containing 0.5 M I_2 and 0.45 MNMBI [15]. Quasi-solid-S2 was the ionic liquid polymer gel consisting of the solution (0.5 M I₂, 0.45 M NMBI in MPII) and PVDF-HFP (10 wt.%) [14]. Quasi-solid-S1 and Quasi-solid-S2 were injected into the sandwiched cells using a vacuum pump, respectively. Solid-S3 was the hybrid PEO/PVDF/TiO₂ nanoparticle solid-state electrolyte and prepared as follow [28]. The polymer-blend solution was composed of 0.080 g PEO and 0.012 g PVDF in 10.0 g the mixture of propylene carbonate and 1,2-dimethoxyethane (DME) (volume ratio = 7:3). Subsequently, 0.029 g TiO₂ nanoparticles (P25) and 2.0 mL the $I^-/I_3^$ redox-couple solution (dissolving 3.042 g LiI and 0.461 g I₂ in 30 mL acetonitrile) were added. At last, the above solution was coated onto the dye-coated TiO₂ film and heated to evaporate the solvent.

2.4. Characterization and photoelectrochemical measurement

X-ray diffraction (XRD) measurements were performed on a Bruker D4 X-ray diffractometer using Cu Ka radiation $(\lambda = 0.15418 \text{ nm})$. The surface/cross section morphologies and the elements of the films were studied by field emissionscanning electron microscope (FE-SEM, JSM-6700F) with energy dispersive spectroscopy (EDS, Oxford INCA model 7421). Nitrogen adsorption/desorption isotherms were measured with a Micromeritics Tristar 3000 analyzer at 77 K. The Brunauer-Emmett-Teller (BET) method was utilized to calculate the surface areas. The total pore volume was estimated from the amount adsorbed at a relative pressure of 0.99. The pore size distributions were calculated from the adsorption branches using the Barrett-Joyner-Halenda (BJH) method. UV-vis absorption spectra of dye-coated films were collected using Shimadzu UV-2550 UV-visnear infrared spectrophotometer with TCO substrate as a blank.

The photocurrent-density/voltage curves were measured in a two-electrode system under illumination (75 mW cm^{-2}) using a computerized Keithley Model 2400 SourceMeter unit. A 1000 W xenon lamp (Thermo Oriel, American) served as the light source. The active electrode area was typically 0.15 cm². The results are not corrected with respect to transmission losses in the conducting substrate. Monochromatic light in the range of 400–800 nm was obtained by using a series of filters, and the

incident photo to current conversion efficiency (IPCE) measurement were performed on a Keithley Model 2400 SourceMeter.

Electrochemical impedance spectroscopy (EIS) measurements of the similar two-electrode system were performed with a Solartron SI 1287 electrochemical interface and a Solartron SI 1250 impedance/gain-phase analyzer. The spectra were obtained by applying sinusoidal perturbations of $\pm 10 \text{ mV}$ at frequencies from 10^{-2} to 10^5 Hz in the dark and under illumination (10 mW cm^{-2}) . The obtained spectra were fitted with Z-View software (V2.70) in terms of appropriate equivalent circuits.

3. Results and discussion

3.1. Preparation and characterization of TiO₂ films

XRD patterns of traditional TiO₂ films and novel ZnO-TiO₂ films were investigated and shown in Fig. 1. There is no obvious difference in XRD patterns between TiO₂-BT and TiO₂-AT, so only XRD pattern of TiO₂-AT is given as shown in Fig. 1A. The diffraction peaks of TiO₂-AT are identified as belonging to both TiO₂ and polycrystalline SnO₂ (TCO glass substrate). The pattern associated with TiO2 reveals a typical anatase structure in good agreement with anatase reference data. After packaging ZnO nanowires into TiO₂ film, the diffraction peaks associated with ZnO are also observed in the pattern of ZnO-TiO₂-BT, besides the diffraction peaks corresponding to TiO₂ with anatase structure. However, the pattern of ZnO-TiO₂-AT is very similar to that of TiO₂-AT, and the diffraction peaks corresponding to ZnO are not found, which indicates that ZnO nanowires have been removed effectively by the acid treatment. In addition, average TiO₂ crystalline sizes are estimated from the full width at half-maximum (FWHM) of the diffraction peak at 25.4° using Scherrer equation $D = 0.9\lambda/\beta \cos\theta$ (where D is the crystal size, λ the wavelength of X-ray radiation, β the full width at half maximum, and θ is the diffraction angle). The estimated TiO₂ particle sizes are about 14 nm for all films, regardless of the presence of ZnO and acid treatment.

The surface morphologies (low magnification) of TiO_2 -BT and ZnO-TiO₂-BT were investigated by field emission-



Fig. 1. XRD patterns of TiO_2 -AT (A), ZnO-TiO_2-BT (B) and ZnO-TiO_2-AT (C).



Fig. 2. The surface morphologies of TiO₂-BT (A) and ZnO-TiO₂-BT (B).



Fig. 3. FE-SEM micrographs showing cross section of TiO2-AT (A), ZnO-TiO2-BT (B) and ZnO-TiO2-AT (C).

scanning electron microscope (FE-SEM) and shown in Fig. 2. Uniform and smooth surface with very little crack is found in TiO₂–BT (Fig. 2A). The surface morphology of TiO₂–AT is similar to that of TiO₂–BT. However, it is clear that there are plenty of cracks with 0.2–1.0 μ m in width and about 10 μ m in length on the surface of ZnO–TiO₂–BT (Fig. 2B). The depth of the cracks was further studied and found to be about 2 μ m. Obviously, the cracks are mainly caused by the introduction of ZnO nanowire in ZnO–TiO₂–BT. It is deduced that the difference of expansion coefficient between TiO₂ and ZnO results in these cracks in ZnO–TiO₂–BT during the annealing process. Moreover, after the acid treatment, these cracks remain changeless in ZnO–TiO₂–AT. Electric measurement indicates that these cracks have no obvious adverse effect on the conductivity of ZnO–TiO₂–AT.

To further investigate the structure of both traditional TiO₂ film and ZnO–TiO₂ film, the cross sections of these films were studied by FE-SEM at higher magnification as shown in Fig. 3. No obvious effect of the acid treatment on the morphologies of traditional TiO₂ films is found, so only the cross section of TiO₂–AT is given (Fig. 3A). It is clear that TiO₂–AT is composed of a three-dimensional network of interconnected particles with the grain size between 10 and 20 nm. However, the addition of ZnO nanowires leads to a great change in the cross sections of ZnO–TiO₂–BT (Fig. 3B). Nanowires with diameter of about 40 nm are easily found and this cross section is very coarse due to the existence of nanowires. On the contrary, no nanowire is observed in ZnO–TiO₂–AT (Fig. 3C), suggesting that the acid treatment leads to the disappearance of ZnO nanowires in good

agreement with XRD patterns. The composition of cross sections of ZnO–TiO₂–BT and ZnO–TiO₂–AT has also been analyzed by energy dispersive spectroscopy (EDS), and the results are shown in Fig. 4. It can be seen from Fig. 4A that ZnO–TiO₂–BT is composed of Ti, Zn and O element, besides Pt element (resulting from vacuum deposition of Pt to increase conductivity). After the acid treatment, Zn element disappears (Fig. 4B), which further confirms the removal of ZnO nanowire in ZnO–TiO₂–AT.

Importantly, as can be seen from Fig. 3(A) and (C), ZnO–TiO₂–AT has more and bigger nanopores than TiO₂–AT. To further investigate these nanopores, the nitrogen adsorption/desorption isotherms and pore size distribution curves of



Fig. 4. EDS pattern of ZnO-TiO₂-BT (A) and ZnO-TiO₂-AT (B).



Fig. 5. Nitrogen sorption isotherms of TiO_2 -AT (A) and ZnO- TiO_2 -AT (B). Insets are BJH pore size distribution curves calculated from the adsorption branches.

both TiO₂–AT and ZnO–TiO₂–AT were measured and shown in Fig. 5. The pore size of TiO₂–AT is centered around 20 nm and the full width at half-maximum (FWHM) of the peak is about 20 nm (the inset of Fig. 5A). Interestingly, the maximum of the pore size of ZnO–TiO₂–AT is 41 nm (the inset of Fig. 5B) and the distribution of pore size for ZnO–TiO₂–AT is quite wider (FWHM of about 45 nm), which further confirm that plenty of bigger nanopores have been formed in ZnO–TiO₂–AT due to the removal of ZnO nanowires. It also can be deduced that some nanopores have the shapes replicated from the morphologies of their mother mold (ZnO nanowires). Such relatively wide nanopores in the film as well as the cracks on the sur-

face can be considered as the textural channels. It can be expected that the textural channels in ZnO-TiO₂-AT are beneficial to the penetration of the quasi-solid/solid-state materials into the nanopores of films. Furthermore, pore volumes and BET surface areas are calculated according to the nitrogen adsorption/desorption isotherm. The pore volume of ZnO-TiO₂-AT $(1.01 \text{ cm}^3 \text{ g}^{-1})$ is nearly tripled compared with that of TiO₂-AT $(0.37 \text{ cm}^3 \text{ g}^{-1})$. Higher pore volume of ZnO–TiO₂–AT may be attributed to the following reason: (1) after the acid treatment, ZnO nanowires have been removed. As a result, the volume of ZnO nanowires contributes to the pore volume. (2) The accumulated pores constructed between ZnO nanowires and TiO₂ nanoparticles are usually higher than that constructed only from TiO₂ nanoparticles. (3) Plenty of ZnO nanowires may form some nano-architectures that supply bigger interspaces and therefore greatly improve the pore volume. (4) The presence of ZnO nanowires can prevent the densification of films and decrease density of TiO₂ nanoparticles, which also increase the pore volume. (5) The crack with in ZnO-TiO₂-AT may have contribution to the pore volume. In addition, BET surface area of ZnO-TiO₂-AT increases to $94.2 \text{ m}^2 \text{ g}^{-1}$ from $80.5 \text{ m}^2 \text{ g}^{-1}$ of TiO₂-AT. This slight increase originates from the presence of the textural channels instead of the change of grain size.

3.2. The performance of DSSCs based on TiO_2 -AT and $ZnO-TiO_2$ -AT

The changes of nanopores and pore volume of TiO₂ film may affect the performance of DSSCs. I-V measurements of DSSCs based on TiO2-AT/ZnO-TiO2-AT electrodes filled with an organic liquid electrolyte (Liquid-S0), two kinds of quasisolid-state electrolytes (Quasi-solid-S1, Quasi-solid-S2) and a solid-state electrolyte (Solid-S3) were performed, respectively. The results under 75 mW cm^{-2} illumination in terms of open circuit voltage (V_{oc}), short circuit current density (J_{sc}), fill factor (ff), overall solar-to-electric energy conversion efficiencies (defined by $\eta = V_{oc}J_{sc}ff/I_{ph}$, where I_{ph} is the incident photon flux) and the improved ratio of η (defined by $y = (\eta ZnO-TiO_2-AT - \eta ZnO-TiO_2)$ $\eta \text{TiO}_2\text{-AT})/\eta \text{TiO}_2\text{-AT} \times 100$ are presented in Table 1. When liquid electrolyte (Liquid-S0) is used, the conversion efficiency of DSSCs based on ZnO-TiO₂-AT (8.17%) increases only by 3.6% in contrast to that (7.88%) of TiO₂-AT system (Table 1). As mentioned above, phase structure, particle sizes and composition

Table 1

 $Comparison \ of \ the \ performance \ of \ DSSCs \ fabricated \ from \ TiO_2-AT \ electrode \ and \ ZnO-TiO_2-AT \ electrode \ (film \ thickness: \ about \ 10 \ \mu m)$

Electrolyte	Film	$V_{\rm oc}$ (V)	$J_{\rm sc}~({\rm mA~cm^{-2}})$	ff	η (%)	Improved ratio (y) (%)
Liquid-	TiO ₂ -AT	0.696	12.60	0.674	7.88	_
so	ZnO-TiO ₂ -AT	0.699	13.10	0.669	8.17	3.6
Quasi-	TiO ₂ -AT	0.658	8.58	0.662	4.98	_
solid-	ZnO-TiO2-AT	0.664	10.57	0.651	6.09	22.3
S1 Quasi-	TiO ₂ -AT	0.656	8.37	0.655	4.80	_
solid-	ZnO-TiO2-AT	0.667	10.14	0.639	5.76	20.2
S2 Solid-	TiO ₂ -AT	0.663	8.13	0.565	4.06	_
S3	ZnO-TiO ₂ -AT	0.669	9.58	0.618	5.28	30.1



Fig. 6. UV–vis absorption spectra of the dye-coated $ZnO-TiO_2-AT$ (A) and TiO_2-AT (B). Spectra are normalized to the absorbance at 400 nm.

of TiO₂–AT are as same as those of ZnO–TiO₂–AT. Generally, the penetration of organic liquid electrolyte into all nanocrystalline TiO₂ films is excellent. Therefore, it can be deduced that the slight improvement of J_{sc} for ZnO–TiO₂–AT system may result from some factors such as the mild increase of the BET surface area (from 80.5 m² g⁻¹ for TiO₂–AT to 94.2 m² g⁻¹ for ZnO–TiO₂–AT).

More importantly, for all DSSCs based on these quasisolid/solid-state electrolytes (Quasi-solid-S1, Quasi-solid-S2, Solid-S3), the conversion efficiencies (η) from ZnO–TiO₂–AT electrodes are larger by 20–30% compared to those from TiO₂–AT electrodes (Table 1). The improvement chiefly results from the remarkable enhancement of short-circuit current density (J_{sc}). Here it cannot be deduced that the great enhancement of J_{sc} (and η) in quasi-solid/solid-state DSSCs based on ZnO–TiO₂–AT is decided by the increase of BET surface area. The main reasons for J_{sc} increase in ZnO–TiO₂–AT systems are investigated as follows.

It has been revealed experimentally and theoretically that by introducing large particles (several hundreds of nanometer) or spherical voids into TiO2 film, the absorbance and IPCE values in longer wavelength range (especially 650-750 nm) can be greatly enhanced through light scattering, which can improve the cell performance [43-48]. In our case, UV-vis absorption spectrum of dye-coated ZnO-TiO₂-AT is similar to that of dyecoated TiO₂-AT as shown in Fig. 6, which indicates that no obvious light scattering can be observed, probably resulting from these facts that the average pore size (about 41 nm) of ZnO-TiO₂-AT is too small and that the micron-sized cracks on the surface is too large. The IPCE values of DSSCs based on both kinds of films filled with Quasi-solid-S1 are plotted versus wavelength in Fig. 7. ZnO-TiO₂-AT system shows better photoelectrical response, and the IPCE between 450 and 650 nm are much higher than that of TiO₂-AT system. On the other hand, the difference between the IPCE values of these two systems in longer wavelength range (especially 650-750 nm) is small as shown in the inset of Fig. 7, which further confirms the fact that the effect of light scattering on the cell performance is negligible. Therefore, the contribution of scattering effect for the



Fig. 7. IPCE spectra of DSSCs fabricated from ZnO–TiO₂–AT and TiO₂–AT electrode filled with Quasi-solid-S1. Inset is the normalized IPCE spectra.

 $J_{\rm sc}$ (and η) improvement of ZnO–TiO₂–AT systems is minor. The main reasons for $J_{\rm sc}$ increase in ZnO–TiO₂–AT systems may be the improvement of the interfacial contact and reaction between the dye-coated TiO₂ film and the electrolyte, which are further studied by FE-SEM and electrochemical impedance spectroscopy (EIS) technique.

The interfacial contact between the dye-coated TiO₂ film and the electrolyte is dependent on the penetration of the electrolyte into the nanopores of the film. The pore filling of the nanoporous TiO₂ layer by quasi-solid/solid-state electrolytes (Quasi-solid-S1, Quasi-solid-S2, Solid-S3) were investigated by FE-SEM. Fig. 8 shows cross-section FE-SEM micrographs of TiO₂-AT and ZnO-TiO₂-AT electrodes filled with Quasisolid-S1. Although the image of the nanoparticles in TiO₂-AT electrode is indistinct (Fig. 8A), we still can distinguish nanoparticles, which reveals that the nanopores of TiO₂-AT is not completely filled. Interestingly, the cross-section (Fig. 8B) of ZnO-TiO2-AT electrode is apparently smooth and homogeneous, and no typical TiO₂ nanoparticle is observed, which suggests that TiO₂ particles are completely covered by Quasisolid-S1 and the pore filling is excellent. The penetration phenomena of Quasi-solid-S2 and Solid-S3 are similar to that of Quasi-solid-S1. These facts suggest that ZnO-TiO₂-AT system exhibits better pore filling by quasi-solid/solid-state electrolytes than TiO₂-AT system, which will result in better interfacial contact in ZnO-TiO₂-AT system.

Electrochemical impedance spectroscopy (EIS) technique has been widely employed to study the kinetics of electrochemical and photoelectrochemical processes occurring in DSSCs [49–53]. We also investigated the effect of the textural channels on the interface and kinetics in DSSCs by EIS technique. The impedance spectra of DSSCs based on TiO₂–AT and ZnO–TiO₂–AT filled with Quasi-solid-S1 were measured at open circuit voltage (OCV, -0.68 V) under illumination and under forward bias (-0.68 V) in the dark [49]. The results are shown in Fig. 9. Experimental data are represented by symbols while the solid lines correspond to the fit obtained with Z-View software using the equivalent circuit shown in Fig. 10. Parameters obtained by fitting the experimental spectra with



Fig. 8. Cross-section FE-SEM micrographs of TiO₂-AT electrode (A) and ZnO-TiO₂-AT electrode (B) filled with electrolyte S1 (TiO₂ film depth: $\sim 6 \mu m$).



Fig. 9. Impedance spectra of DSSCs based on TiO₂–AT and ZnO–TiO₂–AT filled with Quasi-solid-S1. TiO₂–AT system in the dark (\Box) and under illumination (\blacksquare), ZnO–TiO₂–AT system in the dark (∇) and under illumination ($\mathbf{\nabla}$).



Fig. 10. Equivalent circuit of DSSCs.

this equivalent circuit in the frequency ranging from 0.1 to 8×10^4 Hz are shown in Table 2.

The impedance spectra of TiO₂–AT system are similar to that of ZnO–TiO₂–AT system. All spectra exhibit a large semicircle at low frequencies and a small one at high frequencies, which are fitted with a $R_S(R_1C_1)(R_2CPE_2)$ equivalent circuit similar to literature [50,52]. In general, a constant phase element (CPE) is used in the model in place of a capacitor to compensate for inhomogeneity in the system. In the Z-View software, the CPE is defined by two parameters, the value (CPE-T) of capacitance of the CPE element and the change (CPE-P) of the compressed semicircle from an ideal semicircle. The frequency range and the size of the small semicircle (associated with R_1 and C_1 element) suggest that such semicircle is associated with kinetic processes at the Pt counter electrode [50,51]. The low frequency (large) semicircle (associated with R_2 and CPE₂ element) is correlated with the photoelectrode, taking into account the charge-transfer process that occurs across the TiO₂ | redox electrolyte. Both in the dark and under illumination, ZnO–TiO₂–AT systems exhibit lower values for R_2 resistance and higher values for the CPE₂ capacitance (associated with CPE₂-T parameter) than the analogous components of TiO₂-AT system (Table 2), implying more efficient chargetransfer process at the dye-coated ZnO-TiO₂-AT | electrolyte interface (reduction of oxidized dye by I⁻). Furthermore, the impedance at high frequency, associated to the $R_{\rm S}$ element, is 61–62 Ω for TiO₂–AT system and 17–19 Ω for ZnO–TiO₂–AT system (Table 2). Usually, the $R_{\rm S}$ element is related to the series resistance of the electrolyte and electrical contacts in an electrochemical cell. For such solar cells, the $R_{\rm S}$ component can account not only for resistance of the electrolyte, but also for the resistance within the TiO₂ film [52]. The lower $R_{\rm S}$ values observed for ZnO-TiO₂-AT system also reveal better electrical contact and thus more rapid ionic transfer in this device.

Based on the above results, the sketch of quasi-solid/solidstate DSSCs fabricated from ZnO–TiO₂–AT is simulated in Fig. 11. Obviously, the textural channels (micron-sized cracks and the nanopores with diameter of about 41 nm) in ZnO–TiO₂–AT are relatively wider and straighter than the aboriginal nanopores (diameter of about 20 nm) in TiO₂–AT. The

Table 2

Parameters obtained by fitting the impedance spectra of DSSCs fabricated from TiO2-AT and Zn-TiO2-AT filled with Quasi-solid-S1

Film	Condition	$R_{\rm s}\left(\Omega\right)$	<i>C</i> ₁ (µF)	$R_1(\Omega)$	CPE ₂ -T (µF)	CPE ₂ -P	$R_2(\Omega)$
TiO ₂ –AT	Dark Illumination	62 61	14 16	4 3	45 44	0.89 0.90	81 70
Zn-TiO ₂ -AT	Dark Illumination	19 17	6 6	6 3	60 62	0.86 0.87	44 26



Fig. 11. Sketch of DSSCs based on ZnO-TiO2-AT.

electrolytes more easily enter the deep layer of ZnO-TiO₂-AT through the textural channels when they are coated onto the surface of ZnO-TiO₂-AT, which leads to better effects of wetting and pore filling and thus better interfacial contact. Better interfacial contact, confirmed by better electrical contact (lower R_2 resistance and higher CPE₂ capacitance), results in more efficient interfacial reaction (reduction of oxidized dye by I⁻) and thus higher photocurrent. In addition, plenty of electrolytes efficiently enter the textural channel with suitable pore size due to the complete pore filling of ZnO-TiO₂-AT system. Rolison [32] reported that the transport of small molecules in media featuring large mesopores (>10 nm) and macropores (>50 nm) can approach rates of diffusion comparable to those in open medium. We also believe that the transport of molecules or ions (I^-, I_3^-) in the textural channel filled with the electrolytes is very rapid. It even can be thought that for ZnO-TiO₂-AT system, ions have been equivalently transferred to the electrode surface when they are transferred to the textural channel filled with the electrolytes. This rapid transport of ions in ZnO-TiO₂-AT system is confirmed by lower value of R_S . More rapid transport of ions makes the interfacial reaction more effective and thus greatly improves the photocurrent. In brief, most improvement of the cell performance should be attributed to the presence of the textural channel.

4. Conclusions

TiO₂ films with the textural channels are obtained for the first time by a simply way. The presence of textural channels facilitates the penetration of quasi-solid/solid-state electrolytes into TiO₂ film and therefore leads to the great improvement (20–30%) of overall solar-to-electric energy conversion efficiencies. Further improvement can be expected if the channel in TiO₂ film is fine-tuned, for example, by varying the type, diameter and length of nanowire or aligning nanowire. More importantly, the new concept established here will be very helpful in developing other types of TiO₂ film for quasi-solid or solid-state DSSCs.

Acknowledgements

The authors thank Huo Yingdong Education Foundation (104012), National Science Foundation of China (20490210 and 20501006) and Shanghai Sci. Tech. Commun. (05DJ14004 and 06QH14002) for financial support.

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